

A circular stamp from the OIPE (Oficina de la Propiedad Industrial de El Salvador). The outer ring contains the text "OIPE" at the top and "PATENT & TRADEMARK OFFICE" at the bottom. The center of the stamp contains the date "APR 26 2005".

**INFORMATION DISCLOSURE STATEMENT  
BY APPLICANT**  
(Use several sheets if necessary)

(Use several sheets if necessary)

APR 26 2001

Atty. Docket No.  
P24820

**Application No.**  
**09/937,464**

**Applicant**

**Filing Date**  
March 24, 2002

**Group  
1775**

## **U.S. PATENT DOCUMENTS**

## **FOREIGN PATENT DOCUMENTS**

**OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)**

---

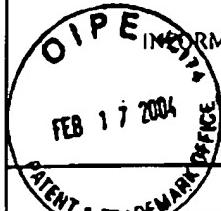
EXAMINER

Laville

**DATE CONSIDERED**

5/5/05

\*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Form PTO-1449		U.S. Department of Commerce Patent and Trademark Office						Atty. Docket No. P24820		Serial No. 09/937,464		
 <b>O I P E INFORMATION DISCLOSURE STATEMENT</b> <b>BY APPLICANT</b> Use several sheets if necessary								Applicant Thomas BENTHIEN et al.				
								Filing Date March 24, 2002		Group 1775		
U.S. PATENT DOCUMENTS												
EXAMINER INITIAL	DOCUMENT NUMBER						DATE	NAME		CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
Mur	6	1	8	7	4	2	6	02/13/01	JONSCHKER et al.	428	292.1	
Mur	5	9	4	8	3	9	8	09/07/99	HANAMOTO et al.	424	RECEIVED 76.1	
Mur	5	6	2	4	6	6	7	04/29/97	MARUO et al.	424	76-21 FED 25 2004	
FOREIGN PATENT DOCUMENTS												
	DOCUMENT NUMBER						DATE	COUNTRY		CLASS	SUBCLASS	TRANSLATION YES      NO
Mur	0	6	0	4	9	1	9	07/06/94	E.P.O.	/	/	
Mur	0	8	4	2	9	6	7	05/20/98	E.P.O.	/	/	
Mur	0	6	4	3	0	1	4	03/15/95	E.P.O.	/	/	
ML	0	4	5	9	0	0	3	12/04/91	E.P.O.	/	/	
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)												
EXAMINER	<u>Caville</u>						DATE CONSIDERED		<u>5/28/04</u>			
*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.												